

Negative Magnetoresistance in High-Mobility Heterostructures

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High-mobility samples: Prof. Werner Wegscheider (Zürich) Dr. Dieter Schuh (Regensburg)

Theory contributions: Dr. Igor Gornyi (Karlsruhe) Prof. Jesus Inarrea (Madrid)



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Magnetoresistance in High-Mobility Sample.



apparently several groups had observed such strange magnetoresistance curves (e.g. Umansky et al. APL 71, 683 (1997), Dai et al. PRL (2010)), but no detailed investigations and no explanations

In the meantime several other experimental observations





Names for Negative Magnetoresistances

| L. Bockhorn, P. Barthold, D. Schuh, W. Wegscheider, and R. J. Haug, Phys. Rev. B 83, 113301 (2011). | | huge |
|---|-----|------------------------------------|
| A. T. Hatke, M. A. Zudov, J. L. Reno, L. N. Pfeiffer, and K. W. West, Phys. Rev. B 85, 081304 (2012). | | giant |
| R. G. Mani, A. Kriisa, and W. Wegscheider, Scientifc Reports 3, 2747 (2013). | | giant |
| Q. Shi, P. D. Martin, Q. A. Ebner, M. A. Zudov, L. N. Pfeiffer, and K. W. West, Phys. Rev. B 89, 201301(R) (2014). | | colossal |
| L. Bockhorn, I. V. Gornyi, D. Schuh, C. Reichl, W. Wegscheider, and R. J. Haug, Phys. Rev. B 90, 165434 (2014). | | giant (rare) |
| Q. Shi, M. A. Zudov, L. N. Pfeiffer, and K. W. West, Phys. Rev. B 90, 201301 (2014). | | colossal |
| L. Bockhorn, J. Inarrea, and R.J. Haug, arXiv 1504.00555 | | huge |
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Overview

- negative magnetoresistances
- magnetoresistance due to oval defects
- current-induced negative magnetoresistance
- size dependence
- conclusions





Sample Structure

GaAs/AlGaAs heterostructure:

- 30 nm quantum well (QW)
- QW located 150 nm beneath the surface
- spacer width 70 nm

2DEG-Parameter : $n_{\rm e} = 3.2 \cdot 10^{11} \,{\rm cm}^{-2}$

 $\mu_{\rm e} = 11.9 \cdot 10^6 \,{\rm cm}^2/{\rm Vs}$







Main Geometry

- Hall bars were defined by photolithography and wet etching
- $n_{\rm e}$ and $\mu_{\rm e}$ are manipulated by using a top gate
- Hall bar dimensions are in the range of the mean free path
- $n_{\rm e} = 3.2 \cdot 10^{11} \,{\rm cm}^{-2}$ $\mu_{\rm e} = 11.9 \cdot 10^{6} \,{\rm cm}^{2}/{\rm Vs}$ $\Lambda = 113 \,{\rm \mu m}$







Basic Facts: Temperature Dependence at Low Temperatures



B (mT)





Two Different Magnetoresistances



Tilted Magnetic-Field Dependence







Top Gate: Density Dependence







Density Dependence of Resistances



scattering from smooth disorder (remote ionized **impurities**)

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Small Peak

- temperature independent below 1 K
- depends only on perpendicular magnetic field: two dimensional

classical effect

not always small

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e.g. classical cyclotron radius of 0.1mm at 0.7mT ???





Quasiclassical magnetotransport in a random array of antidots

D. G. Polyakov,^{1,*} F. Evers,¹ A. D. Mirlin,^{1,2,†} and P. Wölfle^{1,2}



see also:

E.M. Baskin, L.I. Magarill, and M.V. Entin, Zh. Eksp. Teor. Fiz. 75, 723 (1978) [Sov. Phys. JETP 48, 365 (1978)]; E.M. Baskin and M.V. Entin, Physica B 249-251, 805 (1998).





Interplay of Strong Scatterers and Smooth Disorder: Classical Memory Effect



 $\Delta \rho_{xx} / \rho_0 = -\frac{\omega_c^2}{\omega^2}$

situation for high-mobility structures

$$\tau_{s} \sim \tau_{L} \quad \left(\omega_{0} \sim \omega_{perc} \right)$$

 τ_S transport scattering time for strong scatterers





very low density of strong scatterers radius: 10 – 20 µm

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Phys. Rev. B 90, 165434 (2014)

Sample Surfaces







diameter: up to 40µm

density: around 10^4 cm^{-2} \rightarrow inter-defect spacing: $d_{OD} \sim 90 \text{ }\mu\text{m}$

oval defects are always present!

$$\rightarrow l \sim d_{OD}$$

$$\rightarrow \mu \sim 1 \ge 10^7 \text{ cm}^2/\text{Vs}$$





Oval Defects in the Sample







Y. G. Chai and R. Chow, Appl. Phys. Lett. 38, 796 (1981).
G. D. Pettit, J. M. Woodall, S. L. Wright, P. D. Kirchner, and J. L. Freeouf, J. Vac. Sci. Technol. B 2, 241 (1984).

K. Akimoto, M. Dohsen, M. Arai, and N. Watanabe, J. Cryst. Growth 73, 117 (1985).

S.-L. Weng, Appl. Phys. Lett. 49, 345 (1986).

M. Shinohara and T. Ito, J. Appl. Phys. 65, 4260 (1989).



Different Densities of Oval Defects = Different Peak Heights



Huge Peak



temperature dependent, parallel field dependent





Electron-Electron Interaction Correction in the Ballistic Regime

$$\rho_{xx} = \frac{1}{\sigma_0} + \frac{1}{\sigma_0^2} (\mu^2 B^2) [\delta \sigma_{xx}^{ee}(T)]^{-1}$$



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Current-Induced Negative Magnetoresistance



arXiv 1504.00555





Theoretical model for negative giant magnetoresistance in ultrahigh-mobility 2D electron systems

J. IÑARREA



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Analogoue Explanation for Our Results



arXiv 1504.00555

Size Dependence?

L. Bockhorn, A. Hodaei, D. Schuh, W. Wegscheider, and R. J. Haug, J. Phys.: Conf. Ser. 456, 012003 (2013).

presentation at high-magnetic field conference in Chamonix 2012

small peak is not geometry dependent, huge peak shows geometry dependence

Size Dependence

R. G. Mani¹, A. Kriisa² & W. Wegscheider³

SCIENTIFIC REPORTS | 3:2747 | DOI: 10.1038/srep02747

2013

Conclusions

- negative magnetoresistances in high-mobility 2DEGs
- small peak: classical effect due to scattering from oval defects
- huge peak: temperature dependent current induced

• size dependence?

